



RECEIVED  
TECHNOLOGY CENTER 2800  
PATENT  
MAR - 1 2002

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Applicants: Yi-Fan Chen,                    Examiner: Huynh, Andy  
5    Chi-King Pu,  
    Shou-Kong Fan

Filing Date: 04/18/01                      Art Unit: 2818

Serial No.: 09/836,258                      Docket No.: NAUP0280USA

10 Title: BYPASS CIRCUITS FOR REDUCING PLASMA DAMAGE

To:                   Assistant Commissioner for Patents  
    Washington, D.C. 20231

15 Subject: Response to the Office action dated 01/24/02

Dear Sir:

**AMENDMENT**

20

In response to the Office action identified above,  
please amend the above-identified application as follows:

**In the claims:**

25

Cancel claims 7-14.